Workshop on Scale-up and Standardization for Photonic Quantum Technology

Day 1 (October 30th)

All sessions held in the auditorium. Posters and buffet in the foyer

Time	Session	Title
11:30	Registration	NPL Foyer/main entrance. Please collect namebadges.
12:00	Lunch	Poster presenters to put up posters
13:00	Opening	Patrick Parkinson (Manchester): Welcome, context setting
		Fernando Castro (NPL): Formal opening and welcome
13:20	Session 1	1A: Jake Bulmer (PsiQuantum)
		Photonic universal fault tolerant quantum computing
	Chair:	1B: Maddison Coke (Manchester)
	Sebastian	Nanoscale Advanced Materials Engineering Using Focused Ion Beams
	Wood (NPL)	1C: Charlotte Ovenden (Aegiq)
		Single photon sources: applications and scaling
		1D: Anthony Bennet (Cardiff)
		Compound Semiconductor Quantum Light Sources
		1E: Elisa Sala (Sheffield/National Epitaxy Facility)
		Growth and characterization of InAs/InP QDs as efficient light emitters at
		the telecom C-band
		1F: Haotian Zeng (UCL)
		MBE Growth of branched-nanowire quantum dots
15:00	Coffee	
15:30	Session 2	2A: Brian Geradot (Heriot-Watt)
		Probing electronic and photonic interactions in quantum materials
	Chair:	2B: Philip Dolan (NuQuantum)
	Patrick	Datacentre-scale entanglement distribution
	Parkinson	2C: Nate Huang (NPL)
	(Manchester)	Advanced probing of light-matter interaction at nanoscale for quantum
		optoelectronics
		2D: Luca Sapienza (Cambridge)
		Integrated quantum photonics: towards scalable single-photon
		technology
		2E: Josh Nunn (ORCA Computing)
47.45	Destaur	ORCA Computing: The route from NISQ processors to jourt-colerance
17:15	Posters,	Contributed posters, supporter stalls, and served drinks
10.00	Stalls, Drinks	
18:00	Buffet	
19:00	Close	

Workshop on Scale-up and Standardization for Photonic Quantum Technology

Day 2 (October 31st)

All sessions held in the auditorium. Breakout sessions to be announced.

Time	Session	Title
08:30	Breakfast	Coffee/Pastries
08:50	Welcome	
09:00	Session 3	3A: Milos Toth (UTS Sydney)
		Integrated quantum photonics using layered materials
	Chair:	3B: Kolja Haberland (Laytec), Iwan Davies (IQE)
	Denise	The benefit of in-situ metrology for process-control during front-end
	Powell (CSC)	semiconductor manufacturing of photonic quantum devices
		3C: Martin Ebert (CORNERSTONE/Southampton)
		Challenges linked with transitioning nanofabrication to larger substrates
		3D: Friederike Jöhlinger (Wave Photonics)
		Streamlining Photonic Chip Design
		3E: Yameng Cao (NPL)
		Scaling-up imaging-metrology for materials with quantum and photonic
		applications
10:45	Coffee	
11:15	Session 4	4A: Rosemary Scowen (Toshiba)
		Quantum sources and detectors for quantum key distribution
	Chair:	applications
	Yameng Cao	4B: Annika Moslein (Quantum Dice)
	(NPL)	Scaling Quantum Randomness
		4C: Sam Johnson (Innovate UK)
		Commercialising Photonic Quantum Technologies in the UK
		4D: Gavin Jones (BSI)
		Standards Development for Quantum Technologies
12:30	Breakout	Workshop breakout sessions
	discussion	
	Venue TBA	5A: Single photon sources (Fabrication, Characterization)
		5B: Single Photons (Integration and Devices)
		5C: Quantum Computing Applications
13:20	Close	Summary, follow-up
13:30	Lunch	
14:30	End	